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APPLICANT: Burgmair et al.

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EXAMINER: Net-yet-assign Diana Garrity

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

JUL 09 2007

U.S. PATENT DOCUMENTS

EXAMINER INTHATE	<i>E</i>	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	A						
	В						
	С						
	D						
	Е						
	F						
V	G						

FOREIGN PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES NO
/D.G./	Н	DE 103 35 163	3/3/2005	Germany	27	414	Yes-Abstract
/D.G./	Т	GB 2 017 400	10/3/1979	United Kingdom	27	26	
		IP 56100350	8/12/1081	lanan	27	20	Voc Abstract
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/D.G./	L	WO 85/04480	10/10/1985	WIPO	27	00	

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

EXAMIN INITIAL			
000000000000000000000000000000000000000	000000000000000000000000000000000000000	oooooodky fooooo	Matsushima Teshinori et al., "Organic inorganic field effect transistor with Snl-based perovskite channel layer using vapour phase deposition technique," Proceedings of the SPIE-The International Society for Optical Engineering, 2003, Vol. 5217. Pages 43-54 (abstract) CAPLUS [online]
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ENAM	IND		DATE CONCIDENT

EXAMINER

/Diana Garrity/

DATE CONSIDERED

06/24/2008

EXAMINER:

Initial if citation considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not ALL REconsidered Encludesopy of this form with next communication to applicant.